EAST Search History

EAST Search History (Prior Art)

Ref#	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	62570	((apply\$3 or bias) near2 (voltage)) with (alter\$3 or conver\$5 or chang\$3 or insulat\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:01
L2	1144	(TANAKA near2 KOICHIRO). inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:01
L3	239	(ISOBE near2 ATSUO).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:01
L4	914	(YAMAMOTO near2 YOSHIAKI).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:01
L5	15	(L2 or L3 or L4) and L1	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:01
L6	3	"20060270073"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 11:23

L7	19	("20010009222" "20010019129" "20010019129" "20010020887" "20040072411" "20040101989" "20050017239" "20050017239" "20050196883" "20050253178" "20050273290" "2070010057" "5576556" "56867724" "685701" "685705" "685705" "687724" "6911358" FN. OR ("7550382") UHRN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/10/29 11:23
<u>.</u> 8	O	"5676556" "5962897" "6455875" "6559010" "6790749" "6887724" "6911358" 2001/0009222 2001/0019129 2001/0020987 2004/0072411 2004/0101999 2005/0152658 2005/0196883 2005/0253178 November "2005" Yamaquchi et "al." 257/301 2005/0273290 December "2005" Asano et "al." 702/117 2007/0010057	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/10/29
_9	179	"557656" "5062897" "6458875" "6559010" "6790749" "6887724" "6911358" "20010009222" "20010019129" "20010020987" "20040101989" "20050017239" "20050017239" "200500152658 "20050152589" "20050253178" "20050273290" "2007010057"	US-PCPUB; USPAT; USPOT; EPO; JPO; DEFWIBNT; IBM_TDB	OR	ON	2009/10/29 11:26
L10	151	9 and (VOLTAGE OR APPLY \$3 OR BIAS\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 11:26
L11	147	10 AND (SEMICONDUCTOR)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 11:27

L12	701889	((fuse or (anti\$1fuse)) or WOM or (write near2 once) or (IC tage) or (RF tag)) and ((thin film transistor) or (TFT or (thinfilm transistor)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29
L13	4467	(((apply\$3 or bias) near2 (voltage)) with (alter\$3 or conver\$5 or chang\$3 or insulat\$3) with (semiconductor or semi \$1conductor or (amorphous) or crystalline)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29
L14	1081	12 and 13	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 12:42
L15	76	[(((fuse or (anti\struse)) or WOM or (write near2 once) or (IC tage) or (RF tag)) and ((thin film transistor) or (TFT or (thinfilm transistor)))) same (((apply\ssigma) ((apply\ssigma) ((apply\ssigma) or (apply\ssigma) or insulats3) with (alter \ssigma) or insulats3) with ((semiconductor or semi \struck\ssigma) or or (amorphous) or crystalline))	US-PGPUB; USPAT; USOCR; FPPS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29
L21	12	((ffirst and second) (memory cell)) same ((thinfilm transistor) or (thin film transistor) or TFT)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 14:44
L22	1	("20020126108").pn. and ((semiconductor film) or (island))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 15:22
L23	67	(257/16).COLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L24	330	(257/49).OOLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L25	336	(257/52).OOLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L26	3423	(257/59).COLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L27	422	(257/64).OOLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55

L28	278	(257/68).OOLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L29	1240	(257/770-772).OQLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:55
L30	368	(438/153).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:56
L31	1579	(438/166).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:56
L32	2890	(438/238-239).OCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:56
L33	1211	(438/478).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/10/29 15:56
S1	1	"20050174845"	DERWENT	ADJ	ON	2009/10/28 12:30
S3	1	10/573527	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 12:32
S7	2	JP"2004030681"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 12:59
S8	1918	(Jun near2 Koyama) inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:01
S9	651	(semiconductor).ti. and S8	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:02
S10	197	chip and S9	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:02
S11	772	(KATO near2 KIYOSHI).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:17

S12	145	(impurity region) and S11	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:17
S13	135	voltage and S12	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:17
S14	134	gate and S13	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:18
S15	134	memory and S14	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:18
S16	34	(short circuit\$3) and S15	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 13:21
S17	772	(KATO near2 KI YOSHI).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 15:19
S18	52	(((short circuit\$3) or (burn\$3 or alter\$3 or chang\$3)) with (channel or dielectric or insulat\$3)) and S17	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 15:19
S19	23	(((short circuit\$3) or (burn\$3 or alter\$3 or chang\$3)) with (channel or dielectric or insulat\$3) with (voltage or bias or current)) and S17	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 15:31
S20	1	WO "1996007300"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 15:58

S21	21	"5798534"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 15:58
S22	38860	(alter\$3 or chang\$3 or conver \$4) with (semiconductor or (amorphous silicon) or (a \$1\$) or (\$Ge) or (amorphous \$i)) with (voltage or current or bias)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 16:12
S23	1708	((thin film transistor) or (thinfilm transistor)) and \$22	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 16:13
S24	1681	\$23 and (memory or source or drain or gate or dielectric or insula\$5)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 16:13
S25	204	((insulat\$5 or (non\$1conduct \$3)) near2 (state or mode)) and \$24	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/28 17:31
S27	24180	((IC tag) or (write once memory) or WOM)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:43
S28	62570	((apply\$3 or bias) near2 (voltage)) with (alter\$3 or conver\$5 or chang\$3 or insulat\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:44
S29	4	\$27 same \$28	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:44
S30	1	"20090173893"	DERWENT	ADJ	ON	2009/10/29 10:50

S31	2	WO "2006022196"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:52
S32	1144	(TANAKA near2 KOICHI RO) . inv .	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:58
S33	239	(ISOBE near2 ATSUO).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:59
S34	914	(YAMAMOTO near2 YOSHI AKI).inv.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/10/29 10:59

EAST Search History (Interference)

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